

Characterization of H₂O₂ resistant microbes isolated from spacecraft assembly facility

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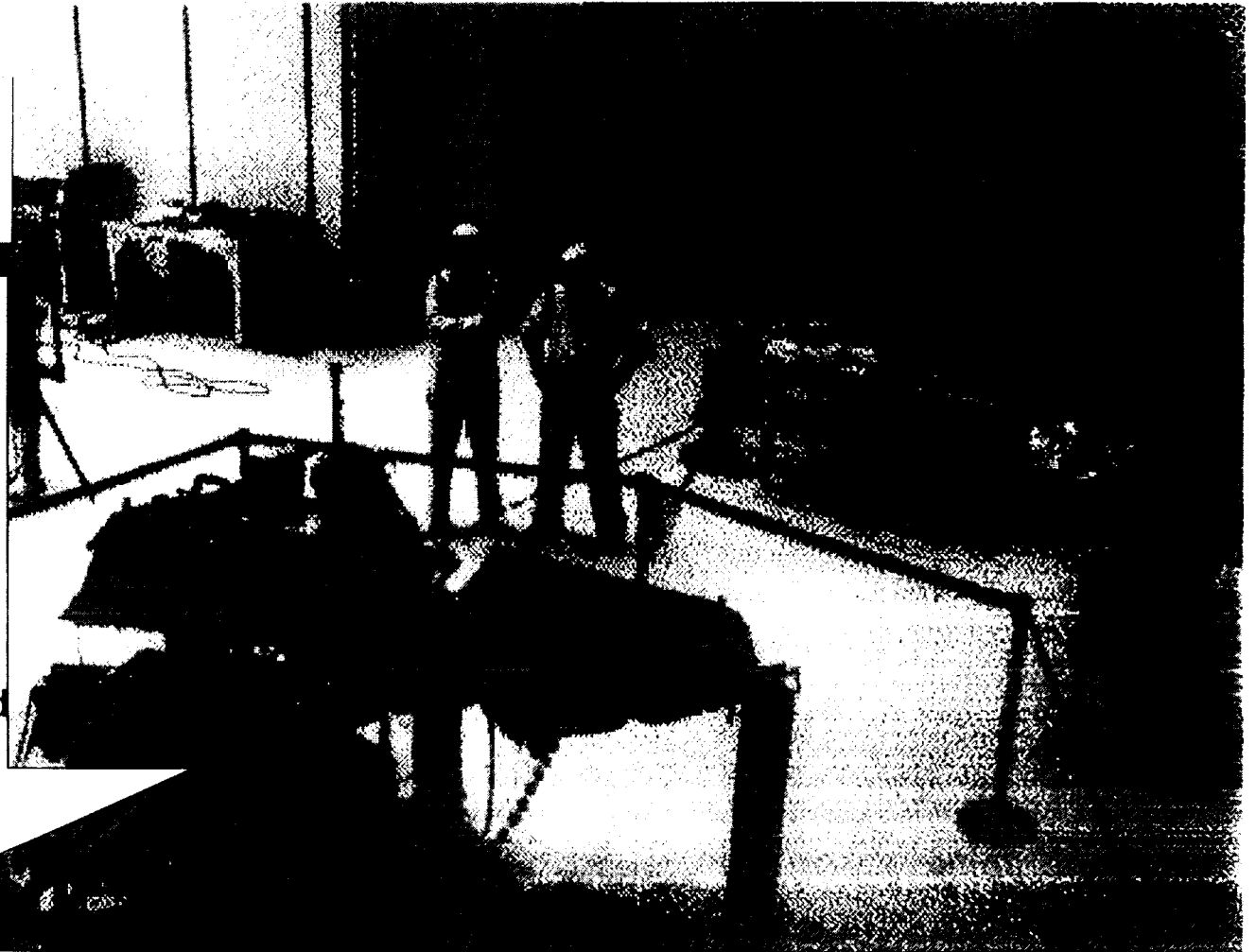
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April 3-5, 2000

Collection of particles

- Stainless steel
- Z307
- S13GLO-1
- 463-3-8
- NS43G

Four of these
paints were coated
on aluminum
(1" x 2")



Witness plates
were exposed for 7
to 9 months at SAF
(High Bay 1)

Assay

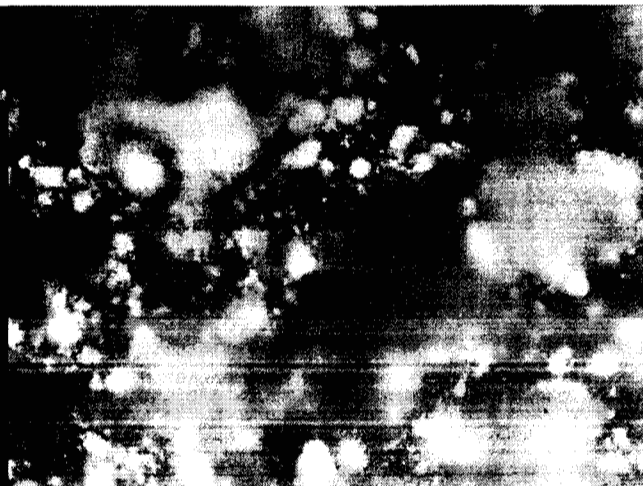
NASA bioburden assay;
Epifluorescence
Microscopy
16S rDNA sequence

Microscopic images of witness plates

Stainless steel



Z-307

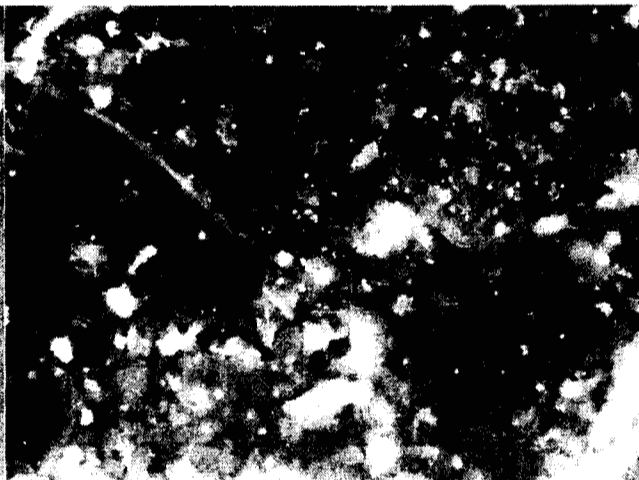


- Hard to differentiate microbes from particles.
- NS43G paint attracts more particles.

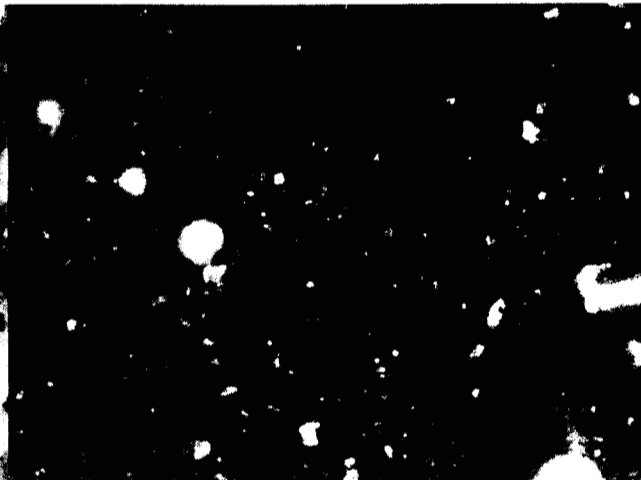
S13GLO-1



NS43G (10x)

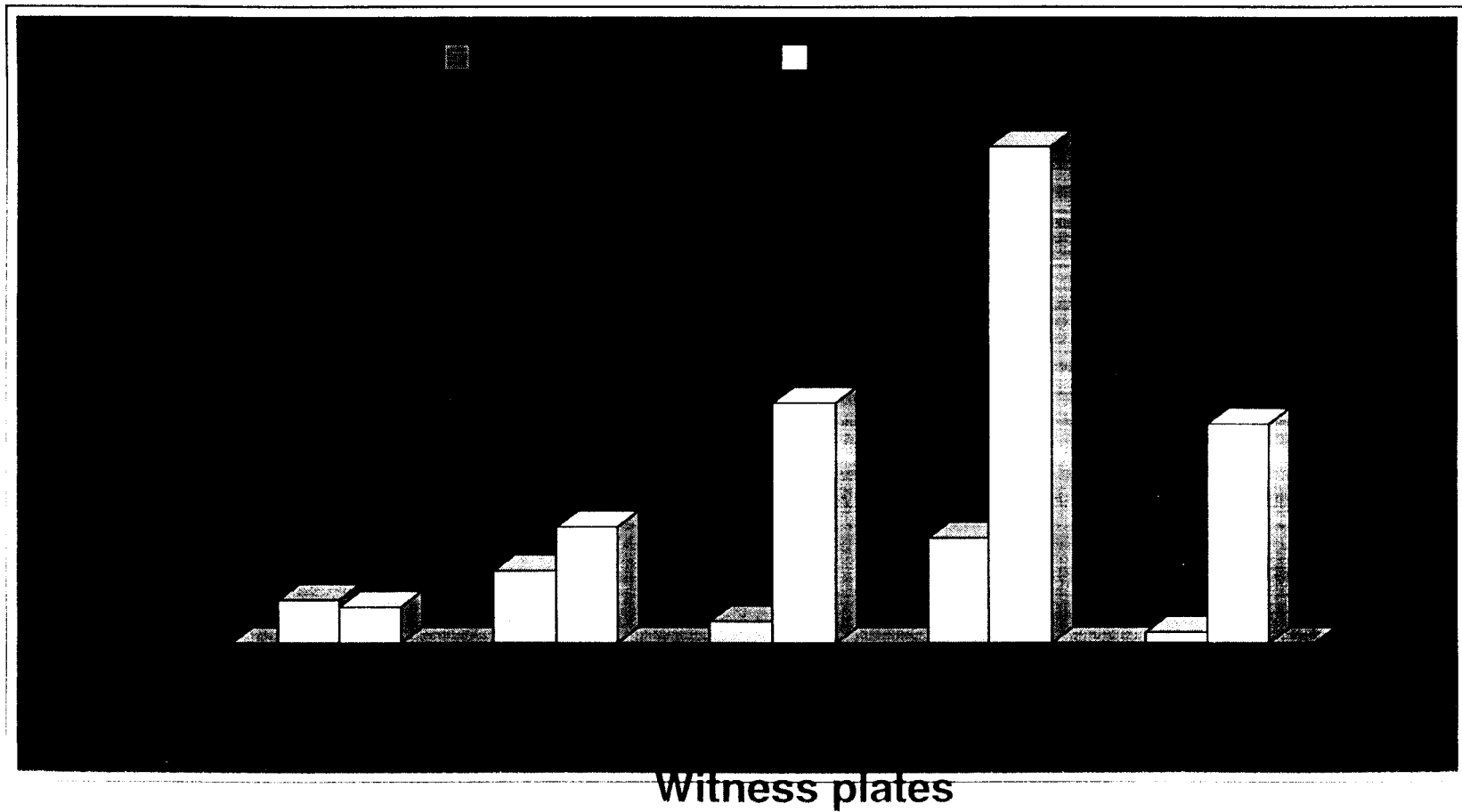


463-3-8



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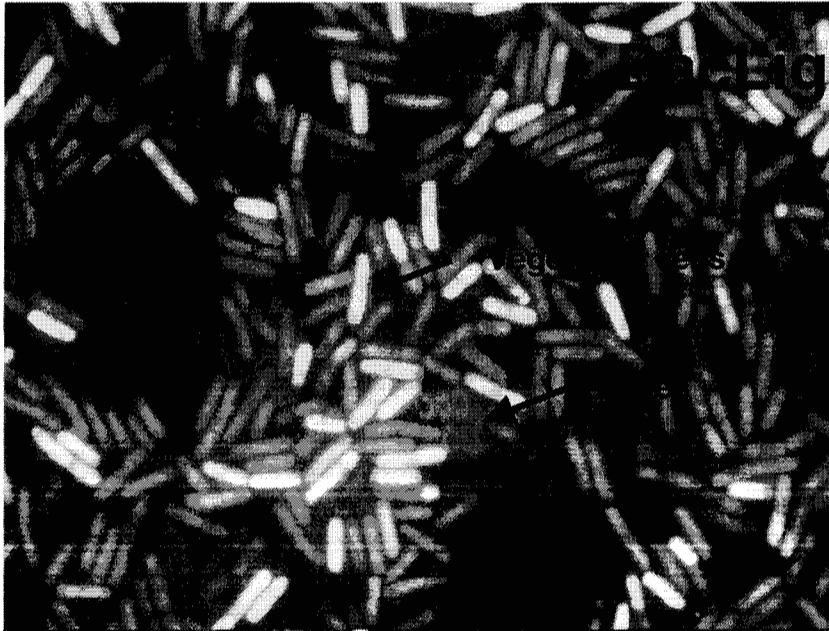
NASA Bioburden Assay



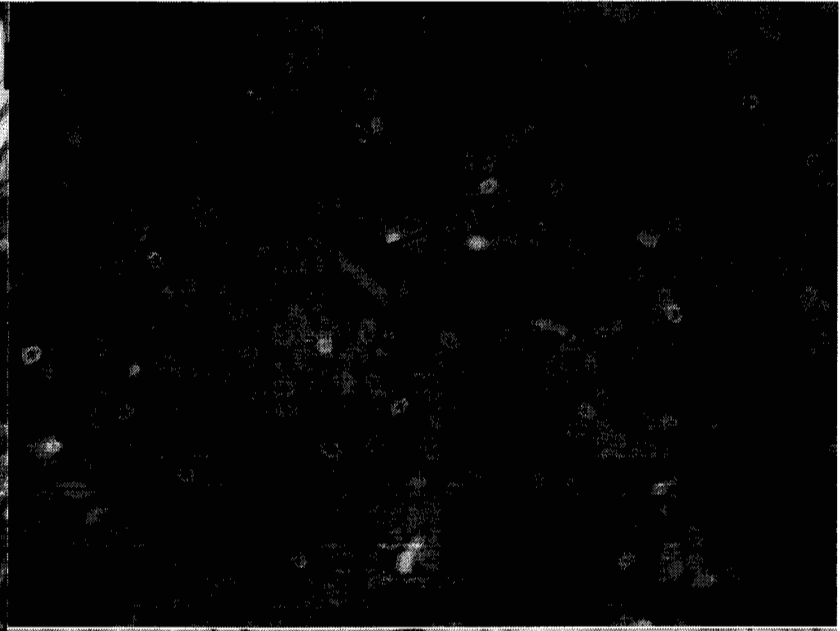
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A novel *Bacillus* species that produce large spore

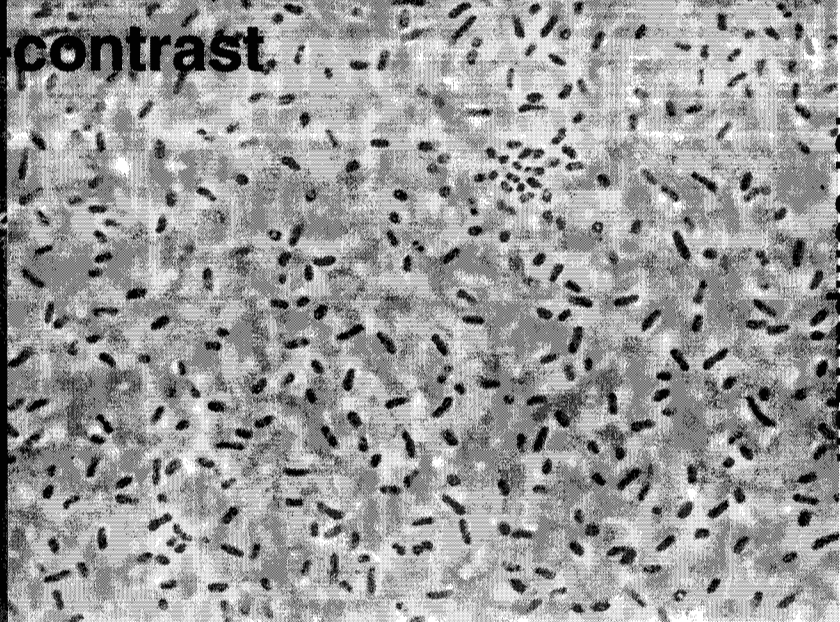
Liquid culture



Agar culture

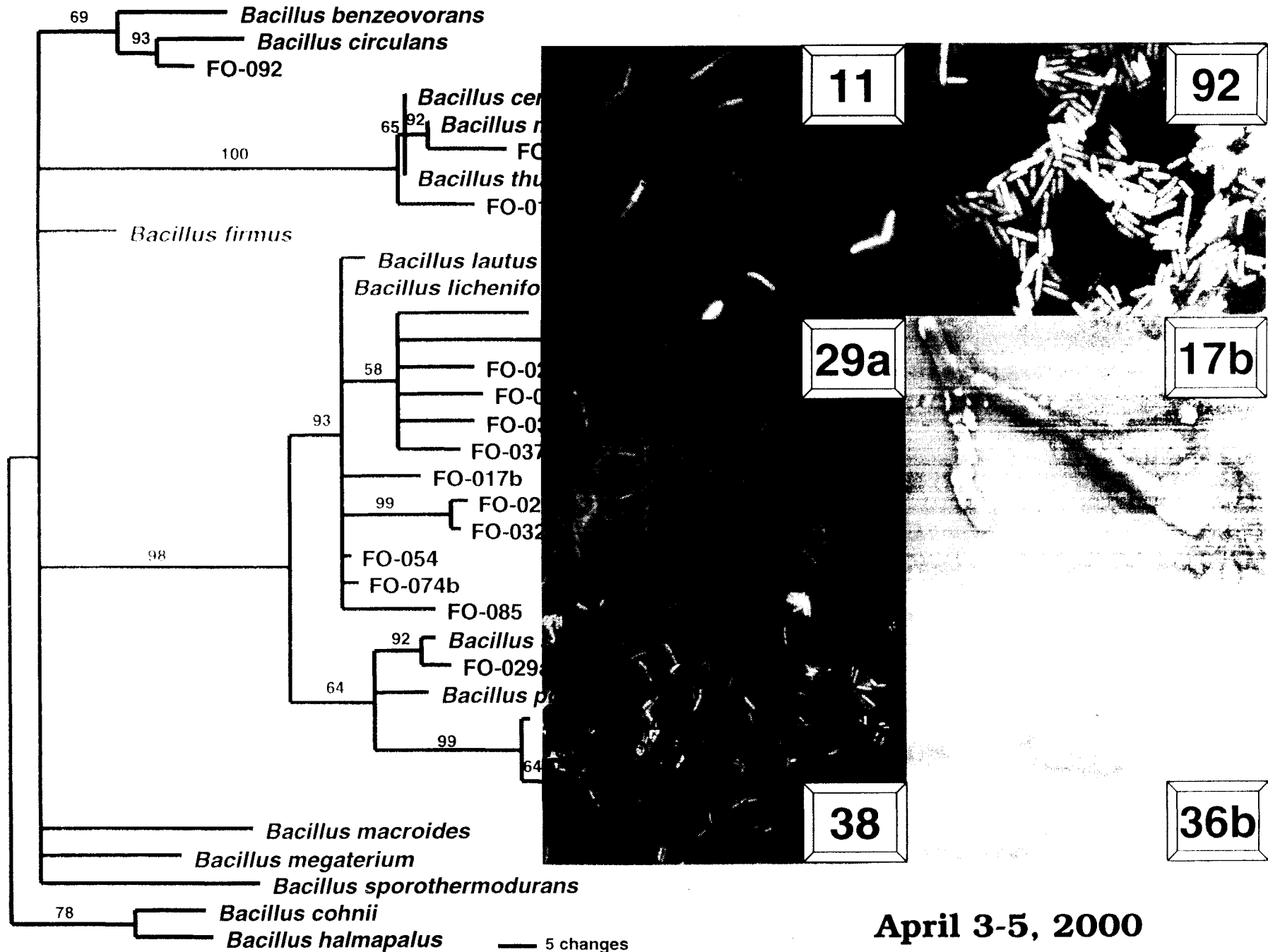


Purified spores



B. megaterium
for comparison

Phylogeny of *Bacillus* species isolated from SAF



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Are SAF conditions extreme?

- **About 44% of 39 strains isolated as per NASA heat shock procedure (85°C for 15-min) and 10% of 40 strains isolated as per NASA standard assay (grown in TSA at 32 °C) showed growth at 60°C.**
- **50% of 89 strains showed growth at high salt concentration (10% NaCl conc.)**
- **Majority of the cultivable microbes were Gram positives and mainly spore-formers.**
- **5% are coccoid.**
- **16S rDNA sequences revealed that majority of the bacterial species are *Bacillus*.**
- **Uncharacterized *Bacillus* species are recognized.**

Morphological changes after H₂O₂ sterilization in Gram-positive microbes

*Bacillus
megaterium*

*Bacillus
subtilis*

*Deinococcus
radiodurans*



All Gram-positive species tested were
susceptible to H₂O₂ (3.6 mg/L)

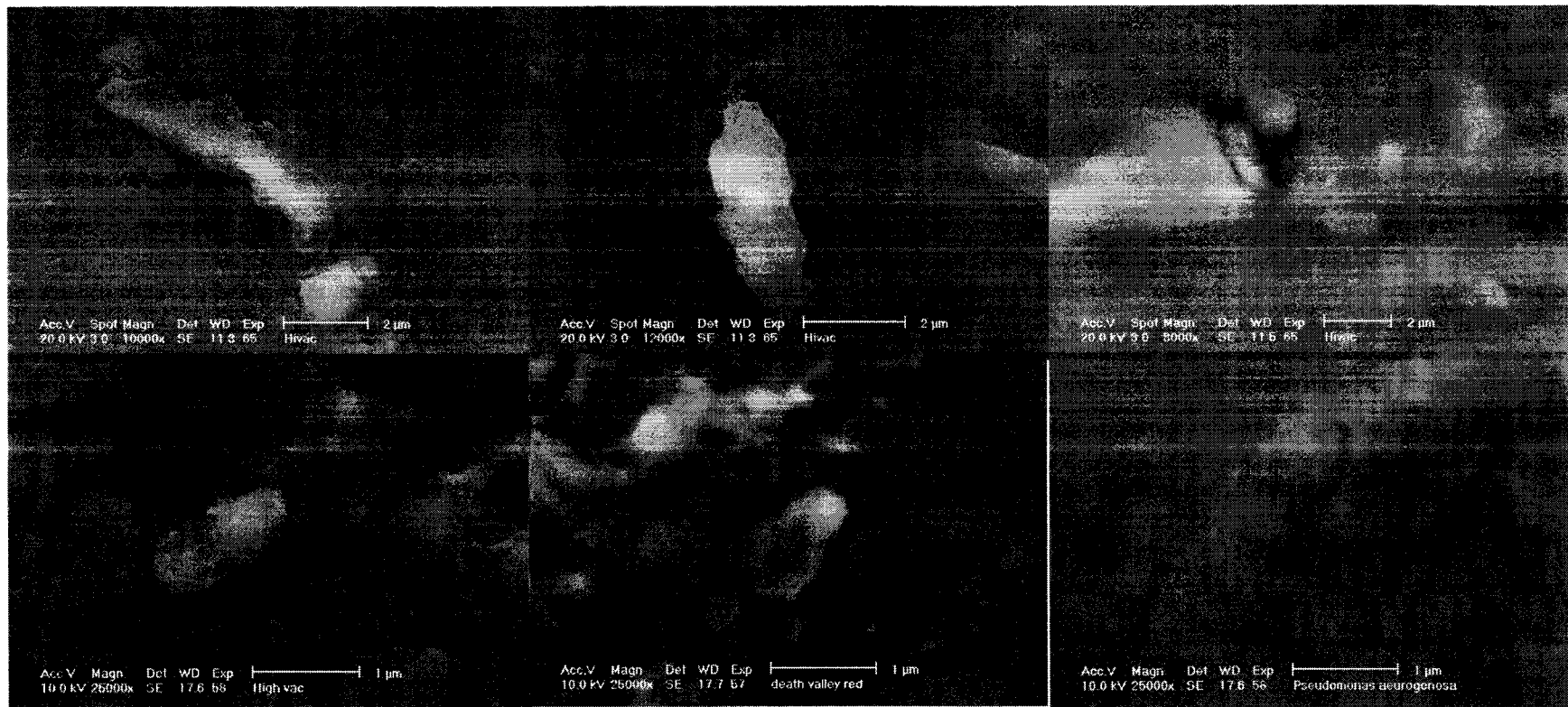
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Morphological changes after H₂O₂ sterilization in Gram-negative microbes

*Escherichia
coli*

*Citrobacter
freundii*

*Pseudomonas
aeruginosa*



All Gram-negative species tested were
susceptible to H₂O₂ (3.6 mg/L)

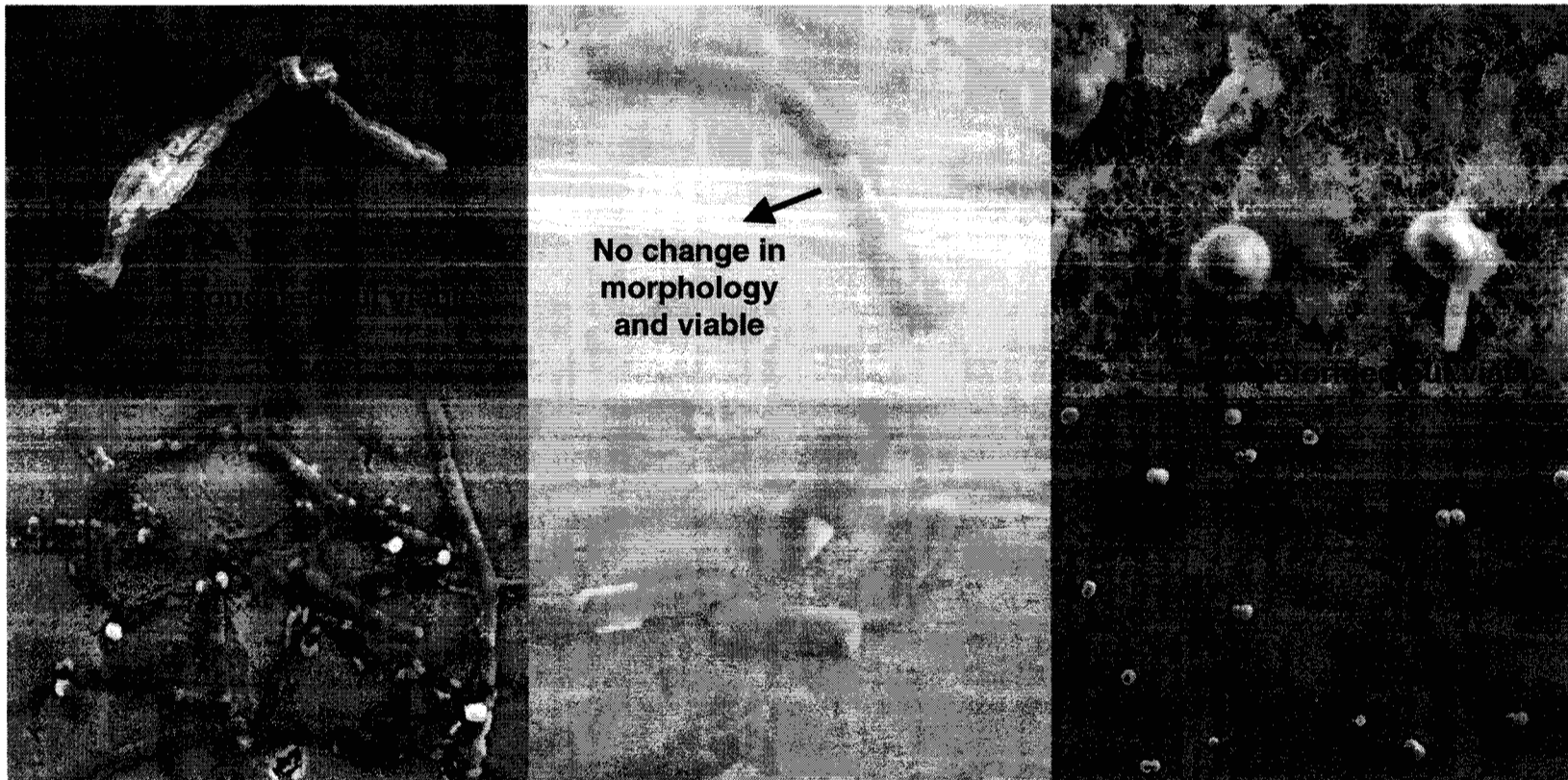
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Morphological changes after H₂O₂ sterilization in microbes isolated from SAF

Bacillus licheniformis
FO-17b

Bacillus pumilus
FO-36b

Staphylococcus
capitis FO-36a

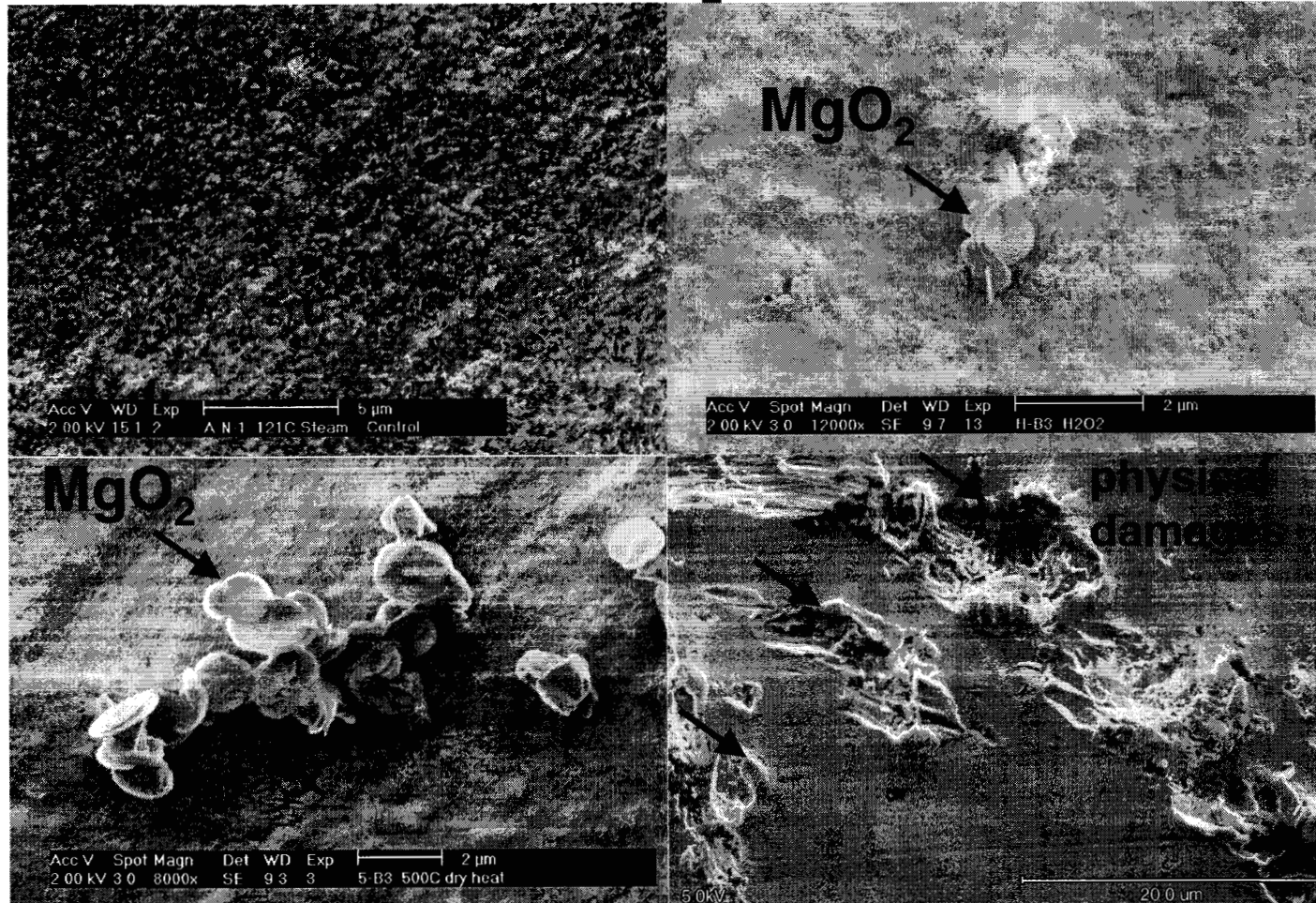


~30% of the SAF microbes were resistant
to various doses of H₂O₂ (4~16 mg/L)

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Oxidation of aluminum 6061 by various sterilization processes

Autoclave
500°C; 60-min.



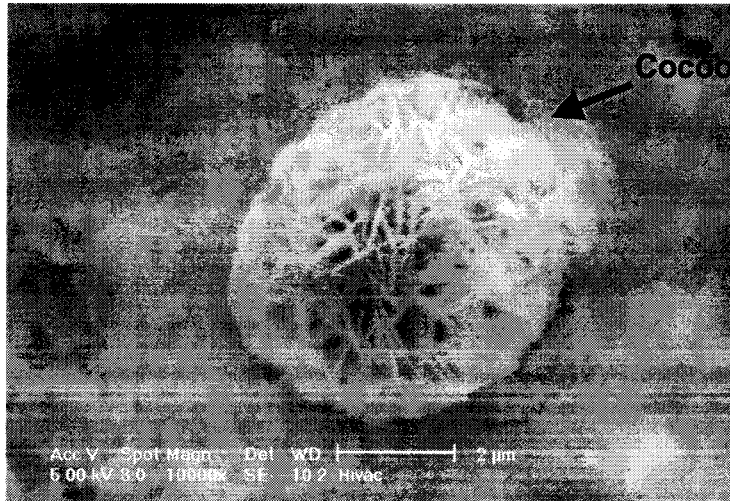
H₂O₂-treated
(4-injections)

Untreated

More Aluminum oxide layers in the order of
500°C > H₂O₂ > Autoclaving > Untreated

Effect of autoclaving in the adhesion of microbial species on aluminum 6061

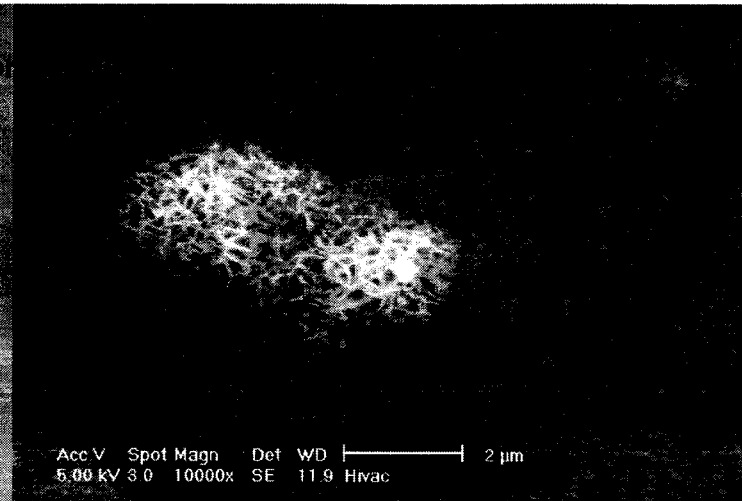
Spore-spiked
18-rms polish;
Autoclaved;



Spore-spiked
mirror polish;
non-autoclaved;



Spore-spiked
mirror polish;
Autoclaved;



B. subtilis cells;
mirror polish;
non-autoclaved



Microbes tend to adhere onto Aluminum surfaces once oxide layers were made available

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Conclusion

✂ The atmosphere of a spacecraft assembly facility should be considered as extreme environment. Many strains isolated from the JPL-SAF were spore-formers and exhibited intense growth at 60°C, and at 10% NaCl. Majority of these cultivable isolates were identified as *Bacillus* species.

✂ 16S ribosomal RNA sequence analysis revealed existence of *Bacillus licheniformis*, *B. pumilus*, *B. cereus*, *B. subtilis*, *Staphylococcus capitis*, *Planococcus citreus* and *Micrococcus lylae*.

✂ A novel uncharacterized *Bacillus* sp. that produce unusually big spores was isolated.

✂ Eight strains exhibited resistance to various doses of H₂O₂ vapor.

✂ *B. licheniformis* (4 strains); *B. pumilus* (3 strains); *S. capitis* (1 strain).

✂ Representatives of various microbes procured from culture collection were susceptible where as 30% of the wild strains isolated from SAF showed resistance to H₂O₂ vapor.

✂ Isolation of microbes that are resistant to H₂O₂ vapor has significant implications for the quality of products in the pharmaceutical and spacecraft industries that depend on low-heat sterilization technology.